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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
09/610,558	07/05/2000	Kiyoshi Sato	9281/3683	3740	
757 759	06/24/2004		EXAM	INER	
BRINKS/HOFER GILSON & LIONE			KLIMOWICZ, WI	KLIMOWICZ, WILLIAM JOSEPH	
P.O. BOX 10395 CHICAGO, IL		ART UNIT PAPER NUM		PAPER NUMBER	
,			2652	a	
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Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)				
	09/610,558	SATO, KIYOSHI				
Office Action Summary	Examiner	Art Unit				
	William J. Klimowicz	2652				
The MAILING DATE of this communication app Period for Reply	ears on the cover sheet with the c	orrespondence address				
A SHORTENED STATUTORY PERIOD FOR REPLY THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a reply If NO period for reply is specified above, the maximum statutory period w Failure to reply within the set or extended period for reply will, by statute, Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	6(a). In no event, however, may a reply be timwithin the statutory minimum of thirty (30) days ill apply and will expire SIX (6) MONTHS from cause the application to become ABANDONEI	nely filed s will be considered timely. the mailing date of this communication. D (35 U.S.C. § 133).				
Status						
1) Responsive to communication(s) filed on 17 Ma	ay 2004.	•				
2a) ☐ This action is FINAL . 2b) ☑ This						
3) Since this application is in condition for allowance except for formal matters, prosecution as to the ments is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.						
Disposition of Claims						
4) ☐ Claim(s) 1-4 is/are pending in the application. 4a) Of the above claim(s) is/are withdraw 5) ☐ Claim(s) is/are allowed. 6) ☐ Claim(s) 1-4 is/are rejected. 7) ☐ Claim(s) is/are objected to. 8) ☐ Claim(s) are subject to restriction and/or						
Application Papers						
9)☐ The specification is objected to by the Examine	•					
10)⊠ The drawing(s) filed on <u>05 July 2000</u> is/are: a)⊠ accepted or b)⊡ objected to by the Examiner.						
Applicant may not request that any objection to the o	• , ,	• •				
Replacement drawing sheet(s) including the correcti 11) The oath or declaration is objected to by the Ex		· · ·				
Priority under 35 U.S.C. § 119						
12) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of: 1. Certified copies of the priority documents 2. Certified copies of the priority documents 3. Copies of the certified copies of the prior application from the International Bureau * See the attached detailed Office action for a list of	have been received. have been received in Application ity documents have been received (PCT Rule 17.2(a)).	on No ed in this National Stage				
Attachment(s)						
Notice of References Cited (PTO-892)	4) Interview Summary	(PTO-413)				
2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date 3.	Paper No(s)/Mail Da 5) Notice of Informal P 6) Other:	ite atent Application (PTO-152)				

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DETAILED ACTION

Election/Restrictions

Applicant's election without traverse of Group I, Species I in the reply filed on May 17, 2004 is acknowledged.

The Applicant's response to the Restriction Requirement included voluntarily canceling non-elected claims 4-9, in preliminary Amendment A (Paper No. 5) filed May 17, 2004, which has been acknowledged.

Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.

Claims 1-3 are rejected under 35 U.S.C. 102(e) as being anticipated by Rudy et al. (US 6,445,536 B1).

As per claim 1, Rudy et al. (US 6,445,536 B1) discloses a thin film magnetic head (e.g., FIG. 10) comprising: a lower core layer (e.g., shield 100); an upper core layer (e.g., 120); at least one insulating layer (e.g., 110) positioned between the lower core layer (100) and the upper core layer (120); a track width restricting groove (e.g., 114) being formed in the insulating layer (110); and *at least one* of a lower magnetic pole layer (e.g., 116) and an upper magnetic pole

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 Al_2O_3).

layer, the lower magnetic pole layer (116) continuing from the lower core layer (100) [the upper magnetic pole layer continuing from the upper core layer], and a gap layer (e.g., 118) positioned between one of the core layers (e.g., 120) and one of the magnetic pole layers (116) that opposes the core layer (120) [or between the two magnetic pole layers being provided in the track width restricting groove], wherein a stopper layer (e.g., 102) is placed, in a portion excluding the track width restricting groove (114), between the lower core layer (100) and the insulating layer (110), and the stopper layer (102) is formed of an insulating material (e.g., metallic Ta or Cr) having an etching rate lower than a reactive ion etching rate of the insulating layer (110) (e.g. SiO₂ or

As per claim 2, wherein the stopper layer (102) is formed to have a film thickness that is smaller than the insulating layer (110) (see, e.g., COL. 4, lines 23-26 and COL. 4, lines 3-5).

As per claim 3, wherein an etching rate of the stopper layer (102) in reactive ion etching is less than the etching rate of the insulating layer by ten times or more (e.g., etch rate for silicon dioxide is known to be at least 10-20 times greater than that of metal tantalum).

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

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Claim 4 is rejected under 35 U.S.C. 103(a) as being unpatentable over Rudy et al. (US 6,445,536 B1).

See the description of Rudy et al. (US 6,445,536 B1), supra.

As per claim 4, Rudy et al. (US 6,445,536 B1) remains silent with respect to buffer etchant stopping layer (102) as being formed of at least one of A1₂0₃ and Si₃N₄.

Official notice is taken that etchant stopping layers as being formed of at least one of A1₂0₃ and Si₃N₄ are notoriously old and well known and ubiquitous in the art; such Officially noticed fact being capable of instant and unquestionable demonstration as being well-known.

It would have been obvious to one of ordinary skill in the art at the time the invention was made to provide the etchant stopping layer (102) of Rudy et al. (US 6,445,536 B1) as being conventional stopping layers formed of A1₂0₃ and Si₃N₄, in lieu of a metal.

The rationale is as follows: one of ordinary skill in the art would have been motivated to provide the etchant stopping layer (102) of Rudy et al. (US 6,445,536 B1) as being conventional stopping layers formed of A1₂0₃ and Si₃N₄, in lieu of a metal in order to a readily available hard dielectric substance not prone to wear or smearing during head manufacture, which is functionally equivalent as a stopping layer when compared to Ta or Cr, as is well known, established and appreciated in the art.

Conclusion

The prior art made of record and not relied upon is considered pertinent to applicant's disclosure.

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Any inquiry concerning this communication or earlier communications from the examiner should be directed to William J. Klimowicz whose telephone number is (703) 305-3452. The examiner can normally be reached on Monday-Thursday (6:30AM-5:00PM).

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Hoa T. Nguyen can be reached on (703) 305-9687. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

William J. Klimowicz Primary Examiner Art Unit 2652

WJK